Tool ID: 510 Tool Location: 128

Equipment Information Sheet

Nabity Nanometer Pattern Generator System (NPGS)

Manager:

Xinwei Wu

607-254-4934

Bark Rp:Bleier

Calls to staff phones will be automatically forwarded to their cell phones during accessible hours. At other times leave a message or send them an email.

SAFETY

No unusual hazards during operation.

USAGE RESTRICTIONS

No buddy system restrictions imposed on normal operation.

SCHEDULING/SIGN-UP RESTRICTIONS

Minimum Tool Time: 0 minutes

Same as Zeiss Supra SEM restrictions, plus:

If you will be using the tool longer than 2 hours you must reserve time outside of normal business hours.

MATERIALS COMPATIBILITY CATEGORY

Tool Category 5: Class A and B Metals and Compounds Allowed Not Allowed Tool category 1/1E, 2, 3, and 4 materials Silicon Based Substrates and Films III/V compound Semiconductors Glass Substrates PECVD and ALD Films Cured organics and baked Photoresist CNF Class A, B, and Refractory metals Exposed Gold, Silver, Copper Alkali and Alkaline Compounds Organic/Biology Molecules preparedw/salt buffers High Vapor Pressure Materials (Mg, Ca, * Some tool restrictions on high vapor pressure materials may apply Soft organic materials

High Vapor Pressure Metals and Compounds are materials that have a vapor pressure above 1e-6 Torr at 400 C.

Additional Material Restrictions and Exceptions

• Never run gun up rapidly to 30 kV; start at 20 kV and increase gradually in small steps to avoid damage to the electron emitter.

Last Updated: 04/20/2023